

In the Abstract:

Please replace the Abstract with the following amended Abstract:

In ~~the~~ a liquid crystal display device, ~~and the method of manufacturing the same,~~ the pixel electrodes-32 and the projection pattern-35 are formed on the TFT substrate 30 side, and surfaces of the pixel electrodes-32 and the projection pattern-35 are covered with ~~the~~ a vertical alignment film-36. ~~Also, the opposing~~ Opposing electrode-44 and ~~the~~ a projection pattern-45 are formed on the CF substrate-40 side, and surfaces of the opposing electrode-44 and the projection pattern-45 are covered with ~~the~~ a vertical alignment film-46. ~~Then, the~~ The TFT substrate-30 and the CF substrate-40 are arranged such that top end portions of the projection pattern-45 on the CF substrate-40 are brought into contact with the TFT substrate-30. ~~Then, the liquid~~ Liquid crystal-49 having ~~the~~ negative dielectric anisotropy is sealed between ~~them~~ the TFT and CF substrates. Accordingly, the step of scattering the spacers can be omitted, change in the cell thickness can be prevented, and the good display quality can be achieved.